

PTO/SB/08A (10-01)

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Substitute for form 1449A/PTO			Complete if Known		
		•	Application Number	09/943,190	
١N	NFORMATION	I DISCLOSURE	Filing Date	August 29, 2001	
STATEMENT BY APPLICANT (use as many sheets as necessary)			First Named Inventor	Kristy A. Campbell	
			Art Unit	2818	
			Examiner Name	Not Yet Assigned	
Sheet	1	2	Attorney Docket Number	M4065.0698/P698	

U.S. PATENT DOCUMENTS					
Examiner	Cita	Document Number	Publication Date	Name of Patentee or Applicant	Pages, Columns, Lines, Where Relevant
Initials*	Cite No. <sup>1</sup>	Number-Kind Code <sup>2</sup> (if known)	MM-DD-YYYY	of Cited Document	Passages or Relevant Figures Appear
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Examiner Initials*	Cite No.1	Foreign Patent Document  Country Code <sup>3</sup> -Number <sup>4</sup> -Kind Code <sup>5</sup> ( <i>if known</i> )	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Т°
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Examiner Signature	Kews N	Phoah ioni	Date Considered	11/19/2007
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<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant

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Cabalitate for form 1440.41.10				Application Number	09/943,190	
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Sheet	2	of	2	Attorney Docket Number	M4065.0698/P698	

		OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS	
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
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